**SNF “Utility Mask” Access Request Form**

Briefly describe the features in your first layer:

________________________________________________________________________
________________________________________________________________________

Describe how/why the features in your first layer can also be defined using the process to create your zero layer:

________________________________________________________________________
________________________________________________________________________

Describe the process you *previously used* to create your alignment marks when your zero and first layers were processed separately:

________________________________________________________________________
________________________________________________________________________

Describe the process you *plan to use* to create your alignment marks when your zero and first layers are processed together:

________________________________________________________________________

**Checklist**

☐ I understand that combining the zero and first layers involves some risk to the integrity of my process. Initials: _____.

☐ I understand SNF staff recommends processing the zero and first layers separately. Initials: _____.

☐ I understand that if I combine zero and first layers, I should not compromise my alignment marks by altering the process to create them. Initials: _____.

☐ I claim responsibility for the extra time and resources I will spend to make combining the zero and first layers work for my process. Initials: _____.

☐ I have read all the background material supplied by SNF staff regarding combining the zero and first layers, in particular the SNF Labmembers Wiki page on this topic. Initials: _____.


☐ I understand that access to the SNF-supplied utility mask is a privilege and access is contingent upon remaining in good standing regarding ASML policies and usage.

User ___________________________________________ Date ____________________